

1997 U.S. PTO

10/025457

12/26/01

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10025457	FILING DATE 12/26/2001	CLASS 430	SUBCLASS	GAU 1752	EXAMINER
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**\*\*FOREIGN APPLICATIONS VERIFIED:**  
JAPAN 2000-395447 12/26/2000  
SRM

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>	
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO	
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		843.41042X00	
Verified and Acknowledged Examiners's initials			
TITLE : Method of manufacturing photomask and method of manufacturing semiconductor integrated circuit device			

U.S. DEPT. OF COMM./PAT. & TM.-PTO-435 (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims	Print Claim for O.G.
<b>ISSUE FEE</b>		<b>DRAWING</b>	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		Print Fig.	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		Applicati n Examiner	
		<b>PREPARED FOR ISSUE</b>	
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